

Application No. 10/674,372  
Amendment filed: November 14, 2005  
Reply to Office Action of July 12, 2005

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Attorney's Docket No.: 042390.P15995

Patent

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In Re Application of:

Frederick Haubensak

Examiner: Elve, Maria Alexandra

Application No.: 10/674,372

Art Unit: 1725

Filed: September 29, 2003

For: WAFER DEFECT REDUCTION BY  
SHORT PULSE LASER ABLATION

Mail Stop Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**AMENDMENT AND RESPONSE**

Dear Sir:

This is in response to the Office Action mailed July 12, 2005. Applicant respectfully requests the Examiner to consider the following remarks.

**FIRST CLASS CERTIFICATE OF MAILING**

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail with sufficient postage in an envelope addressed to Mail Stop Amendment, Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450 on

November 14, 2005

Date of Deposit

Vanessa Sanchez

Name of Person Mailing Correspondence

Vanessa Sanchez  
Signature

11/14/05  
Date

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